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Permalink

https://escholarship.org/uc/item/3dv3v1n7

Journal

Applied Physics Letters, 91(5)

ISSN

0003-6951

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Publication Date

2007-07-30

Dramatic morphological change of scallop-type Cu_6Sn_5 formed on "001… single crystal copper in reaction between molten SnPb solder and Cu

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Wetting reaction between molten Sn-based solders and Cu produces scallop-type Cu_6Sn_5 . In the present wetting study, a 001 single crystal Cu is used as substrate and a dramatic change in the morphology of Cu_6Sn_5 is observed: instead of scallop type, the authors observed a rooftop-type Cu_6Sn_5 grains, elongated along two preferred orientation directions. This was confirmed by electron beam backscattered diffraction and white beam synchrotron x-ray microdiffraction. The results indicate that the nucleation, growth, and ripening behavior of Cu_6Sn_5 on single crystal substrate can be quite different from the conventional case of wetting on randomly oriented polycrystalline Cu substrates.

Because of the wide application of solder, especially Pbfree, in consumer electronic products, the study of the wet-

preferred orientation relationships. There are six types of preferred orientation relationships between the two phases, and in all cases the 101 direction of Cu_6Sn_5 is parallel to

the 110 direction of Cu. The six orientation relationships are as follows:

$$(010) \; \text{Cu}_6 \text{Sn}_5 || (001) \text{Cu} \; \; \text{and} \; \left[-110 \right] \; \text{Cu}_6 \text{Sn}_5 // \left[110 \right]_{\text{Cu}} , \qquad \quad 1$$

$$(343)_{\text{Cu}_6\text{Sn}_5} \| (001)_{\text{Cu}} \text{ and } [-101]_{\text{Cu}_6\text{Sn}_5} \| [110]_{\text{Cs}},$$
 2

$$(-34-3)$$
Cu₆Sn₅ $||(001)$ Cu and $[-101]$ Cu₆Sn₅ $||[[110]]$ 3

$$(101)c_{u_6}s_{n_5}||(001)c_{u_6}$$
 and $[-101]$ $c_{u_6}s_{n_5}||[110]$ c_{u_7} , 4

$$(141)_{\text{Cu}_6\text{Sn}_5} \| (001)_{\text{Cu}} \text{ and } [-101]_{\text{Cu}_6\text{Sn}_5} \| [110]_{\text{Cs}},$$
 5

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$$(-14-1)c_{u_6}s_{n_5}||(001)c_{u}$$
 and $[-101]c_{u_6}s_{n_5}||[110]_{C_{11}}$. 6

This is because a low misfit of 0.24% between the Cu atoms can be achieved along the $^{-}01_{\text{Cu}_6}s_{n_5}$ direction and the

 $110_{\,\mathrm{Cu}}$ direction. The above relationships can be classified into two groups based on the strong pseudohexagonal symmetry around Cu atom in Cu_6Sn_5 when projected along the 1^-01 direction Fig. 2 . Crystal planes in Eqs. 1 - 3 correspond to edges of the Cu hexagon group 1 and Eqs. 4 - 6 correspond to diagonals of the Cu hexagon group 2 .

Since the low misfit directions between Cu_6Sn_5 and Cu lie on the 001 plane of Cu, it is of interest to investigate the behavior of Cu_6Sn_5 formed on 001 single crystal Cu. Single crystal Cu substrates were purchased from Goodfel- low and they have a diameter of 1 cm and a thickness of 0.25 cm. The surface was carefully polished, cleaned, and etched before being immersed in flux. Wetting samples were prepared by reacting small beads 0.5 mg of 55Sn45Pb

in wt % solder with the 001 single crystal copper in flux at 200 $^{\circ}$ C with different reaction times ranging from 30 s to

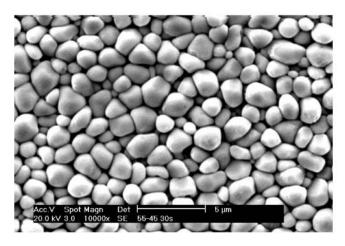


FIG. 1. Top-view scanning electron microscopy SEM image of Cu_6Sn_5 scallop-type grains on a Cu.

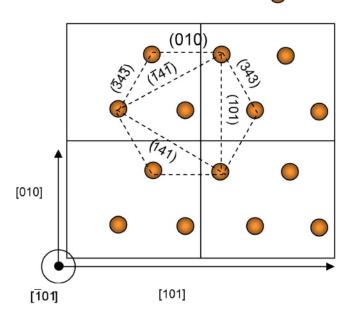


FIG. 2. Color online Structure of Cu_6Sn_5 projected from the 101 direction.

4 min. The molten solder forms a cap on the Cu upon wetting. After a given time of reaction, samples were quenched to room temperature by dipping them into acetone. After solidification, the unreacted solder was removed by mechanical polishing, followed by selective chemical etching in order to expose the interfacial Cu_6Sn_5 scallops.

Figure 3 shows the morphology of Cu₆Sn₅ formed on 001 Cu substrate. Elongated and rooftop-type Cu₆Sn₅ grains were distributed on the entire surface. The elongations go along two perpendicular directions. We hypothesized that Cu₆Sn₅ should elongate along the low misfit direction in or- der to minimize interfacial energy with Cu. Electron beam backscattered diffraction EBSD analysis was performed to verify the elongation direction. Because of the high rough- ness of the sample see Fig. 3, performing EBSD mapping is an issue. However, since each grain is a single crystal, a single Kikuchi pattern coming from a selected spot of an elongated grain is enough to determine its orientation. Kiku- chi patterns were obtained separately from the 001 single crystal Cu substrate and Cu₆Sn₅ grains, and we found that Cu₆Sn₅ grains are elongated along two different 110 directions. Figure 4 a is a Kikuchi pattern from the Cu substrate. Figures 4 b and 4 c are the respective Kikuchi patterns of an elongated grain and of another grain elongated perpen- dicularly to the first one. The analysis indicated that the

001 plane of Cu is perpendicular to the surface normal, and that the 110 directions are nearly parallel within 4° to the laboratory x and y axes. The Kikuchi pattern shown in Fig.



FIG. 3. Morphology of rooftop-type Cu₆Sn₅ formed on 001 Cu.

parallel to the 001 plane of Cu. For the Kikuchi pattern in Fig. 4 c the 101 direction of Cu₆Sn₅ was perpendicular to

the 1 $^{-}$ 01 direction of the other Cu_6Sn_5 and was parallel to the $^{-}$ 10 direction of Cu. Again, one of the group 2 planes was parallel to the 001 plane of Cu. In summary, from EBSD, it was confirmed that Cu_6Sn_5 grains were elongated along their $^{-}$ 01 direction, parallel to the 110 directions of the single crystal Cu.

To obtain statistical data of the orientation distribution, synchrotron white beam micro-x-ray diffraction was performed. The micro-x-ray diffraction experiments were conducted on beamline 7.3.3 at the Advanced Light Source in Lawrence Berkeley National Laboratory. 13 The sample with 4 min reaction time was scanned under a micron size x-ray beam. At each step of scan, a Laue pattern was collected using an xray charge coupled device detector. The micro-x- ray beam can penetrate through the Cu₆Sn₅ and reach the Cu. Therefore, each Laue pattern is a composite of diffraction spots from Cu₆Sn₅ and Cu. The strongest Laue spots came from the Cu due to its larger grain size and thus contribution to the signal. The Cu reflections were indexed first to yield Cu grain orientation and then removed from the list of reflections for the subsequent analysis of the Cu₆Sn₅ reflections.

Figure 5 a is a histogram of the angles between the 001 direction of Cu and the 101 direction of Cu_6Sn_5 , after the 4 min reaction at 200 ° C. An area of 25 30 m² was scanned with a step size of 0.5 m in both x and y directions. There is a strong peak at 90°, indicating that the $^-01$ 1 directions of most of the Cu_6Sn_5 scallops are lying on the 001 plane of Cu. Figure 5 b is a histogram of the angles $^-$ between the 010 direction of Cu and the 101 direction of Cu_6Sn_5 . There are two peaks: one peak is at 45° and the other is at 135°. It indicates that the $^-01$ directions of most of the Cu_6Sn_5 grains are parallel to the 110 or $^-10$ direc-

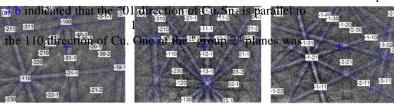
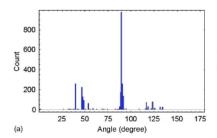


FIG. 4. Color online Kikuchi patterns from the EBSD analysis. a Kikuchi pattern from the Cu substrate. b and c are Kikuchi patterns of a Cu_6Sn_5 grain and another grain perpendicular to the first scallop, respectively.



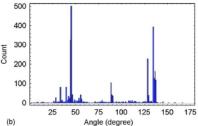


FIG. 5. Color online a Histogram of angle between the 001 direction of Cu and the $^-01$ direction of $^-1$ Cu₆Sn₅, after 4 min reflow at 200 $^{\circ}$ C. b Histogram of angle between the 010 direction of Cu and the $^-01$ direction of Cu₆Sn₅.

tion of Cu. The above results confirm the existence of a strong preferred orientation relationship between $\mathrm{Cu}_6\mathrm{Sn}_5$ and 001 Cu on the bases of EBSD and synchrotron micro-x-ray diffraction.

The dramatic change in morphology of Cu_6Sn_5 suggests that nucleation, growth, and ripening mechanisms of the elongated Cu_6Sn_5 can be different from the rounded scallop- type Cu_6Sn_5 . Figure 6 is a SEM image of Cu_6Sn_5 scallops on 001 Cu after 30 s reflow. Clearly Cu_6Sn_5 already has very strong texture. The strong texture of Cu_6Sn_5 indicates that nucleation of the Cu_6Sn_5 is not random but rather oriented when 001 Cu is used as a substrate. Soldering is a reactive wetting. When molten solder spreads on copper $_{14}$ dissolution

of copper substrate takes place at the interface. If the orientation of substrate copper is a high-index *hkl* plane, more copper will be required to be dissolved away in order to expose the low misfit 110 crystal directions and 001 planes of Cu. Therefore, the nucleation of Cu₆Sn₅ will not have enough time to nucleate with the preferred orientation if the Cu substrate is a high-index plane, and random nucleation will become dominant. However, if the substrate is a 001 single crystal Cu, Cu₆Sn₅ can directly nucleate on the low misfit direction and plane. As a result, Cu₆Sn₅ grains will have an oriented nucleation and textured growth.

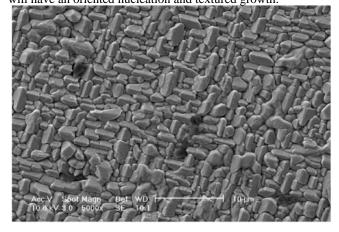


FIG. 6. Color online SEM image of Cu_6Sn_5 grains on 001 Cu, after 30 s reflow.

Due to the strong orientation relationship between the elongated Cu_6Sn_5 and 001 Cu, as shown in Fig. 3, we expect a lower interfacial energy between them than that between the round scallop-type Cu_6Sn_5 and polycrystalline Cu, as shown in Fig. 1. Indeed when we etched the Cu_6Sn_5 , we found that the elongated Cu_6Sn_5 on 001 has lasted much longer in the etchant. The lower interfacial energy will improve the impact fracture toughness of the interface.

In summary, a dramatic change in morphology of Cu_6Sn_5 was found when Sn-based solder was reacted with a 001 single crystal Cu. Grains of Cu_6Sn_5 become elongated along the two low misfit directions between Cu_6Sn_5 and Cu. The relationship between the morphology and the crystallographic orientation was verified by EBSD study. Statistical distribution data obtained by white beam synchrotron micro-x-ray diffraction agreed with the EBSD study. The Cu_6Sn_5 already showed strong texture at 30 s of wetting reaction, indicating that the grains tend to nucleate with texture.

This study was performed at UCLA, supported by SRC under Contract No. NJ-1080 and NSF under Project No. 0503726. The Advanced Light Source is supported by the Director, Office of Science, Office of Basic Energy Sciences, of the U.S. Department of Energy under Contract No. DE-AC02-05CH11231.

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